

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re application of

Kazumasa KAMACHI et al.

Confirmation No. 3974

Serial No. 10/551,818

Mail Stop: PCT

Filed June 22, 2006

Attorney Docket No. 2005_1535A

METHOD AND APPARATUS FOR THE METHANE FERMENTATION TREATMENT OF WASTEWATER CONTAINING SULFUR COMPOUND

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

A corrected filing receipt is requested in the above-referenced case. A copy of the original filing receipt is enclosed, with the changes noted thereon.

Expedited issuance of the corrected filing receipt is respectfully requested.

Respectfully submitted,

Kazumasa KAMACHI et al.

By

Michael S. Huppert Registration No. 40,268 Attorney for Applicants

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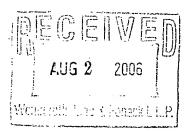
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS	
10/551,818	06/22/2006	1724	1030	.2005_1535A	10	7	2	

CONFIRMATION NO. 3974

513 WENDEROTH, LIND & PONACK, L.L.P 2033 K STREET N. W. SUITE 800 WASHINGTON, DC 20006-1021



FILING RECEIPT OC000000019757249

Date Mailed: 08/01/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Power of Attorney: The patent practitioners associated with Customer Number 513.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/04403 03/29/2004

Foreign Applications

JAPAN 2003-094373 03/31/2003

If Required, Foreign Filing License Granted: 07/25/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/551.818**

Projected Publication Date: 11/02/2006

Non-Publication Request: No

Early Publication Request: No

Title

apparatus

Method and eystem for the methane fermentation treatment of wastewater containing sulfur compound

Preliminary Class

210

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